# **Supply Chain Explorer**

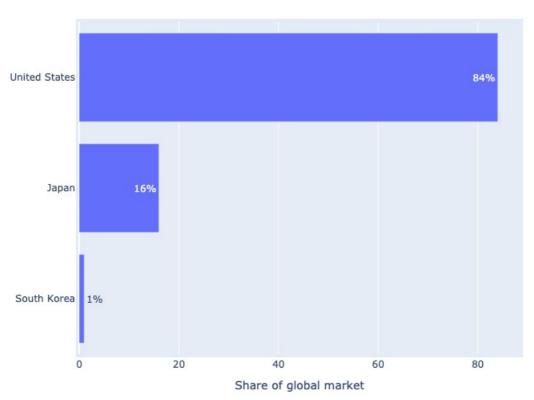
### By the Emerging Technology Observatory

This is an export from the ETO Supply Chain Explorer, available at: <a href="https://chipexplorer.eto.tech">https://chipexplorer.eto.tech</a> You can see the web version of this content at <a href="https://chipexplorer.eto.tech/?filter-choose=input-resource&input-resource=N50">https://chipexplorer.eto.tech/?filter-choose=input-resource=N50</a>.

## **Conductor etching tools**

The main types of dry etching tools are used either for etching conductors or dielectrics. Major subtypes of conductor and dielectric dry etching tools include sputter etching and plasma etching; plasma etching is further divided into reactive ion etching and deep reactive ion etching (a form of reactive ion etching used to make deep wells). The most commonly used form is reactive ion etching.

### **Country provision**



#### Notable supplier companies

- · Applied Materials United States
- Hitachi Japan
- · Lam Research United States
- NAURA China (mainland)
- Tokyo Electron Japan